

Supplementary Data

This supplementary data is a part of a paper entitled “Enhanced UV Resistance of Poly(methyl methacrylate) Through Schiff Base and Metal Oxide Nanoparticle Incorporation”.

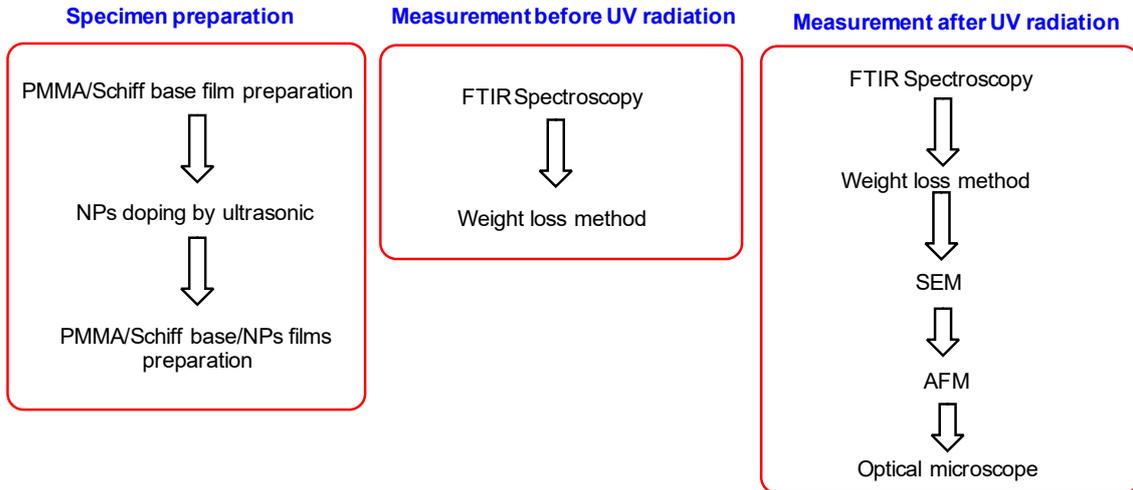
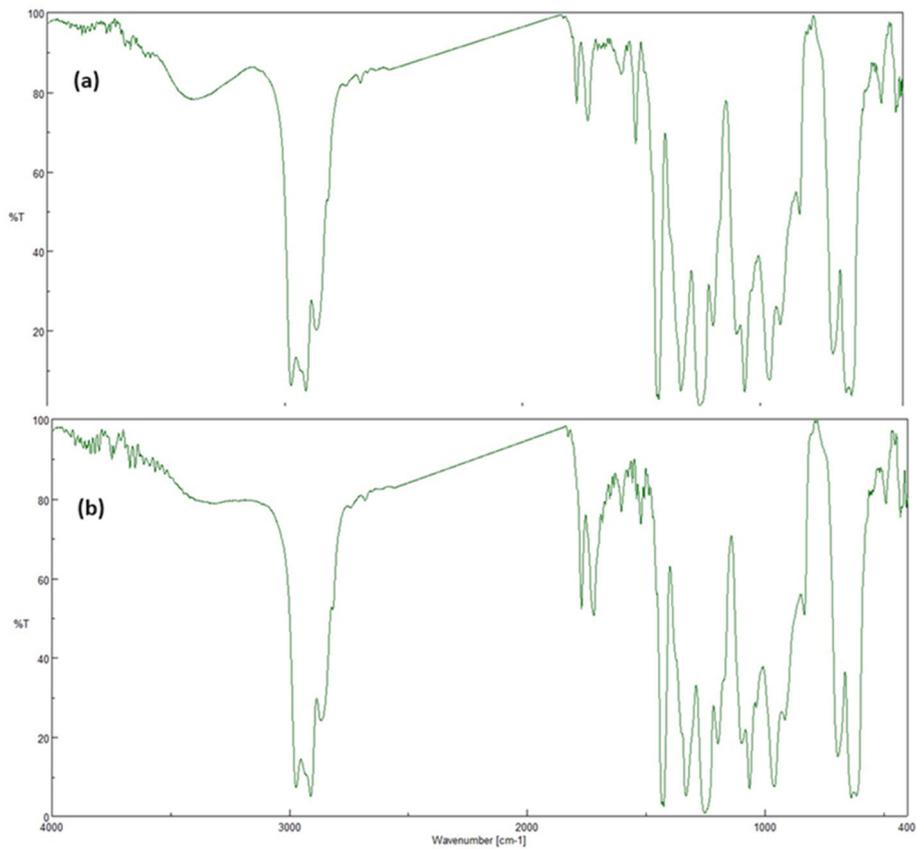


Fig S1. The schematic diagram of the experimental process



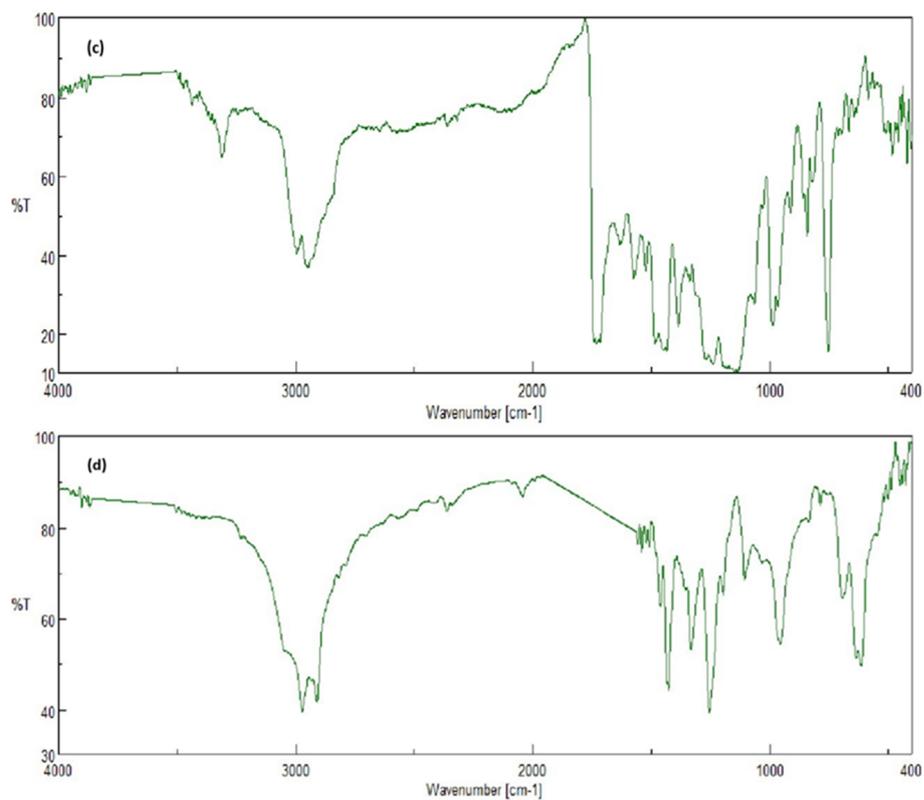


Fig S2. FTIR Photodegradation of PMMA (a) before and (b) after UV irradiation. While (c) and (d) are for the PMMA filled with NiO NPs before and after irradiation, respectively